



KIBABII UNIVERSITY

UNIVERSITY EXAMINATIONS 2020/2021 ACADEMIC YEAR

FOURTH YEAR FIRST SEMESTER MAIN EXAMINATIONS

FOR THE DEGREE OF BACHELOR OF EDUCATION SCIENCEAND BSc (Physics)

COURSE CODE:

SPH 423

COURSE TITLE:

SOLID STATE PHYSICS II

DURATION: 2 HOURS

DATE: 19/07/2021

TIME: 2:00-4:00PM

INSTRUCTIONS TO CANDIDATES

Answer QUESTION ONE (Compulsory) and any other two (2) Questions.

Indicate **answered questions** on the front cover.

Start every question on a new page and make sure question's number is written on each page This paper consists of 3 printed pages. Please Turn Over

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QUESTION ONE (30 MARKS)

- a) Distinguish between intrinsic semiconductor and extrinsic semiconductors. (2 marks)
- b) In an extrinsic semiconductor, majority carriers and minority carriers play a major role in the electric conductivity. Let N_d be the donor impurity density, N_a the acceptor impurity density, p the density of holes and n the density of electrons in an extrinsic semiconducting material. Show that the density of holes and electrons in extrinsic semiconductor material is given by

$$n = \frac{(N_d - N_a) \pm \sqrt{(N_d - N_a)^2 + 4n_i^2}}{2}$$

(3 marks)

State some factors that influence conductivity of a semiconductor?

(3 marks)

- A superconducting tin has a critical temperature of 3.7 K at zero magnetic field and a critical field of (4 marks) 0.0306 Tesla at 0 K. Find the critical field at 2 K.
- (2 marks) What are the functions of donor and acceptor impurities?
- Define the following terms as used in superconductivity f)

(1 mark)

i) Zero resistivity ii) Transition temperature

(1 mark)

iii) Critical magnetic field

(1 mark) (1 mark)

iv) Critical current

(1 mark)

v) Penetration depth

(1 mark)

vi) Isotope effect

For a semiconductor the Hall Coefficient is given by $R_H = -\frac{1}{e} \frac{p\mu_p^2 - n\mu_n^2}{(p\mu_p - n\mu_n)^2}$ where μ_p and μ_n are the mobilities of holes and electrons respectively. Show that for an intrinsic semiconductor the above

expression reduces to $R_H = -\frac{1}{n_i e} \left(\frac{\mu_n + \mu_p}{\mu_n - \mu_p} \right)$

(4 marks)

Differentiate between substitutional solid solutions and interstitial solid solutions. h)

(2 marks)

Differentiate between paramagnetic materials and antiferromagnetic materials i)

(2 marks)

What do understand by crystal imperfections? j)

(2 marks)

QUESTION TWO (14 MARKS)

Differentiate between conductors, semiconductors and Insulators in terms of

i) electrical conductivity

(3 marks)

ii) band gap width

(3 marks)

- b) Find the conductivity and resistivity of a pure silicon crystal at temperature 300°K. The density of electron hole pair per cc at 300°K for a pure silicon crystal is 1.072×10^{10} and the mobility of electron μ_n = 1350 cm²/volt-sec and hole mobility μ_h = 480 cm²/volt-sec (4 marks)
- c) A silicon wafer is doped with phosphorus of concentration 10¹³ atoms/cm³. If all the donor atoms are active, what is its resistivity at room temperature? The electron mobility is 1200 cm²/Volt-sec charge on the electron is 1.6×10^{-19} Coulomb. (4 marks)
- Define hall effect and explain five uses of hall effect

(6 marks)

QUESTION THREE (20 MARKS)

- a) Explain the following properties of superconductors
- i) Energy gap

(4 marks)

ii) Specific heat

(4 marks)

b) The equation of motion of superconducting electrons is given by a transitory electric field E is

$$m\frac{dv_s}{dt} = -e\mathbf{E}$$

By defining current density of superconducting electrons derive London's first equation

(6 marks)

c) By applying the Maxwell equations;

$$curl E = -\frac{\partial \mathbf{B}}{\partial t}$$

To the London's first equation show that;

$$\frac{d}{dt}\left(\frac{m}{n_s e^2}(\nabla \times \boldsymbol{j}_s) + \boldsymbol{B}\right) = 0$$

(6 marks)

QUESTION FOUR (20 MARKS)

- a) Differentiate between magnetic permeability (μ) and magnetic susceptibility (χ_m) (2 marks)
- b) State and explain the three types of magnetism. Illustrate the arrangement of their respective magnetic moments in presence and absence of applied magnetic field. (12 marks)
- c) The magnetization with in a bar of some metal alloy is $1.2x10^6$ A/m at an H field of 200 A/m. Compute the following; (μ_0 =1.257x10⁻⁶ H/m)
 - i) The magnetic permeability

(2 marks)

ii) The magnetic susceptibility

(2 marks)

iii) The magnetic flux density with in this material

(2 marks)

iv) What types of magnetism would you suggest as being displayed by this material? Why? (2 marks)

QUESTION FIVE (20 MARKS)

- a) Write brief notes on each of the following types of dislocations; use diagrams to illustrate how each one of them is formed
 - i) Edge dislocation

(6 marks)

ii) Screw dislocation

(6 marks)

b) Briefly explain the following point defects

(8 marks)

- i) Vacancies
- ii) Interstitial defect
- iii) Frenkel defect
- iv) Schottky Defect